

ROBERT E. BUSHNELL*†

JOSEPH G. SEEBER°

JOHN C. BROSKY°+*

DARREN R. CREW+*

MATTHEW J. LESTINA†*

SARYADVINDER S. SAHOTA†*

RICHARD H. STERN°

MICHAEL D. PARKER

DANIEL A. GESELOWITZ, Ph.D.

(REG. PATENT AGENTS)

† ADMITTED IN MARYLAND

° ADMITTED IN VIRGINIA

+ ADMITTED IN PENNSYLVANIA

‡ ADMITTED IN NEW YORK

° ADMITTED IN CONNECTICUT

* NOT ADMITTED IN D.C.

Assistant Commissioner for Patents
Washington, D.C. 20231

R. E. BUSHNELL

ATTORNEY AT LAW

1522 K STREET, N.W., SUITE 300

WASHINGTON, D.C. 20005-1202

UNITED STATES OF AMERICA

18 April 2001

INTELLECTUAL PROPERTY LAW

TELEPHONE (202) 408-9040

FACSIMILE (202) 289-7100

FACSIMILE (202) 628-3835

FACSIMILE (410) 747-0022

E-MAIL: REBUSHNELL@AOL.COM

☐ U.S. Postal Service

☐ Via Local Courier

☐ Via International Courier

☐ Via Facsimile No. _____

☐ Via E-Mail Attachment

☐ Please Acknowledge Receipt



Attorney Docket: P56342

Sir:

Submitted herewith is the following patent application:

Inventor: 1) DEOK-HYEON CHOE
2) JONG-HAN RHEE
3) SANG-HO JEON
4) YOUNG-BIN IM

Title: TENSION MASK FOR COLOR CRT, METHOD FOR
MANUFACTURING THE TENSION MASK, AND EXPOSURE
MASK USED IN THE MANUFACTURE OF THE TENSION
MASK

Please find attached hereto an application for patent which includes: Specification and Abstract,
Claims, and a certified copy of the foreign priority document identified below:

Verified Showing of Small Entity Status: **NO**

Drawings: Formal drawings, 13 sheets, Figures 1-19

Claim of priority under 35 U.S.C. §119: **YES**

** The Republic Of Korea Application No. 2000-20994 filed on 20 April 2000.

FEE (see formula below): CHECK IS NOT ENCLOSED

Basic Fee \$355/710 **\$710.00**

Additional Fees:

Total number of claims in excess of 20: 13 times \$9/18 . **\$234.00**

Number of independent claims in excess of 3: 1 times \$40/80 **\$80.00**

Multiple Dependent Claims \$135/270 **\$0.00**

An Assignment is likewise enclosed: Recording Fee \$40 . . **\$0.00**

Filing Non-English specification **\$0.00**

TOTAL FEES FOR THE ABOVE APPLICATION **\$1,024.00**

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Assistant Commissioner for Patents

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Docket No.: P56342

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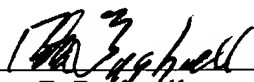
Title: TENSION MASK FOR COLOR CRT, METHOD FOR
MANUFACTURING THE TENSION MASK, AND EXPOSURE
MASK USED IN THE MANUFACTURE OF THE TENSION
MASK

In view of the above, it is requested that this application be accorded a filing date pursuant to 37 CFR 1.53(b).

Please address all correspondence to:

Robert E. Bushnell
1522 K Street, N.W.
Suite 300
Washington, D.C. 20005

Respectfully submitted,



Robert E. Bushnell
(Registration No. 27,774)
Payor No.: 008-439
Attorney for the Applicant
1522 K Street, N.W.
Suite 300
Washington, D.C. 20005

Telephone: (202) 408-9040
Telefacsimile: (202) 628-0755

REB/sb

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